

Novel Metal-Insulator Transition at the SmTiO₃/SrTiO₃ Interface

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(Received 2 March 2017; published 9 June 2017)

We report on a metal-insulator transition (MIT) that is observed in an electron system at the SmTiO₃/SrTiO₃ interface. This MIT is characterized by an abrupt transition at a critical temperature, below which the resistance changes by more than an order of magnitude. The temperature of the transition systematically depends on the carrier density, which is tuned from $\sim 1 \times 10^{14}$ to 3×10^{14} cm⁻² by changing the SmTiO₃ thickness. An analysis of the transport properties shows non-Fermi-liquid behavior and mass enhancement as the carrier density is lowered. We compare the MIT characteristics with those of known MITs in other material systems and show that they are distinctly different in several aspects. We tentatively conclude that both long-range Coulomb interactions and the fixed charge at the polar interface are likely to play a role in this MIT. The strong dependence on the carrier density makes this MIT of interest for field-tunable devices.

DOI: 10.1103/PhysRevLett.118.236803

Metal-to-insulator transitions (MITs) that are caused by strong electron correlations are the source of some of the most interesting phenomena in condensed matter physics [1–4]. They can occur either at very high carrier densities, where on-site Coulomb interactions are strong (“strongly correlated systems”), or at ultralow densities, where long-range Coulomb interactions remain unscreened. The corresponding insulating states are the Mott insulator and the Wigner crystal, respectively. Real materials are often significantly removed from either one of these ideal states and contain additional, complex interactions. Furthermore, disorder, which even without correlations can cause localization (“Anderson insulator”) [5], can play a central role [6,7]. Transition metal oxides with metallic densities (\sim one electron/primitive unit cell) have been central to the study of Mott insulators [2], whereas low-dimensional, low-density (sheet densities on the order of 10^{11} cm⁻² and below) semiconductors are employed in the search for a Wigner crystal in the solid state [8].

Electron systems at oxide interfaces offer access to a parameter space that is not easily available in the systems mentioned above. Unlike doped or alloyed bulk transition metal oxides, electrostatic doping (for example, by a polar discontinuity [9–11]) avoids dopant atoms, a source of disorder. Unlike two-dimensional electron gases in semiconductors, electron masses are high, which promotes localization. Spin-orbit coupling via Rashba fields can also be strong, which may enhance interactions [12]. There are, however, significant challenges. In particular, low carrier mobilities result in high sheet resistances. If these exceed the Mott-Ioffe-Regel limit or quantum resistance ($h/e^2 \sim 25$ k Ω/\square), systems are insulating at most temperatures. This insulating state preempts correlation-induced MITs or other phenomena that may emerge out of an itinerant correlated electron system. MITs near

the Mott-Ioffe-Regel limit have been observed in electron systems at LaAlO₃/SrTiO₃ [13] and SmTiO₃/SrTiO₃ interfaces [14].

Here, we study SmTiO₃/SrTiO₃ interfaces that have sheet resistances well below the quantum limit. The polar discontinuity at such interfaces corresponds to a fixed positive charge of 3×10^{14} cm⁻² at the interface (Fig. 1), which can be compensated by free (mobile) carriers in the SrTiO₃ [15]. Mobile carrier densities of 3×10^{14} cm⁻² per interface are observed for a wide range of sample geometries [11,16]. When SmTiO₃ layers are reduced to a few unit cells (u.c.), the sheet carrier densities are reduced below this value and depend systematically on the SmTiO₃ thickness [14]. Given carrier densities that are not close to either one of the two limiting cases discussed above, conventional wisdom would suggest that a correlation-driven MIT is unlikely to occur. Contrary to this expectation, we show that an abrupt MIT occurs in this interfacial electron system as the temperature is lowered. A transition temperature that scales systematically with the carrier density and other characteristics point to the importance of electron correlations.

Epitaxial SrTiO₃ layers (thicknesses of 20, 60, and 80 nm) were grown using molecular beam epitaxy on (001) (La_{0.3}Sr_{0.7})(Al_{0.65}Ta_{0.35})O₃ single crystals. Following SrTiO₃ growth, epitaxial SmTiO₃ layers with thicknesses of 3, 5, 7, and 20 u.c., respectively, were deposited *in situ* (all thicknesses refer to the pseudocubic u.c. parameter of SmTiO₃, ~ 3.91 Å). Details of the growth have been reported elsewhere [19,20]. Electron beam evaporation through a shadow mask was used to deposit Au/Ti (400/40 nm) contacts for Hall and sheet resistance (R_s) measurements using square van der Pauw structures. Temperature- (T -) dependent electrical measurements were carried out using a Quantum Design physical property measurement system.

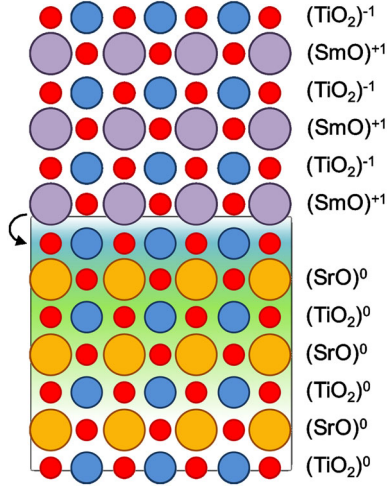


FIG. 1. Schematic of the $\text{SmTiO}_3/\text{SrTiO}_3$ interface, showing the formal charges carried by the layers. The polar discontinuity corresponds to a fixed charge at the interface, which can be compensated by $1/2$ mobile electrons per interface unit cell, or $\sim 3 \times 10^{14} \text{ cm}^{-2}$. The SmTiO_3 surface has a similar polar problem and various ways of potentially resolving it (adsorbates, nonstoichiometry, etc.) [15]. For thick SmTiO_3 , interfaces have the full $3 \times 10^{14} \text{ cm}^{-2}$ mobile charge density, but for thin SmTiO_3 , the carrier density is reduced. It is likely that this is due to the proximity to the polar surface. A significant fraction of the mobile electrons, specifically those that are located in $d_{xz,yz}$ orbitals, spread out far into the SrTiO_3 [17,18]. The degree to which the electron gas spreads is determined by a number of boundary conditions, including the carrier density and field-dependent permittivity of SrTiO_3 . The SrTiO_3 thickness thus affects the spatial distribution.

Figure 2(a) shows the temperature dependence of R_s of several different heterostructures. All samples, except the structure with 20 u.c. of SmTiO_3 , which has nearly the full ($3 \times 10^{14} \text{ cm}^{-2}$) carrier density, exhibit abrupt MITs, with resistance changes exceeding an order of magnitude. (The sample with 20 u.c. of SmTiO_3 shows only a small upturn at low temperatures that could be due to weak localization but is not a sharp MIT as in the other samples.) In most cases, the resistances in the insulating states quickly exceeded the measurement limit, and the actual resistance changes are likely much larger. Measurements taken during heating resulted in the same characteristics (no hysteresis was observed), showing reproducible MITs. The MIT temperature (T_{MIT}) was sample dependent and varied from $\sim 40 \text{ K}$ (7 u.c. $\text{SmTiO}_3/60 \text{ nm}$ SrTiO_3) to near room temperature (260 K for the 3 u.c. $\text{SmTiO}_3/20 \text{ nm}$ SrTiO_3 sample). Furthermore, all structures that were still metallic at 110 K showed a hump in R_s at that temperature. This resistance anomaly is more visible in the derivative, dR_s/dT vs T , shown in Fig. 2(b) (see the arrow). From Fig. 2(b), we see that the anomaly occurs for all samples at $\sim 110 \text{ K}$, irrespective of T_{MIT} . Thus, the two features are

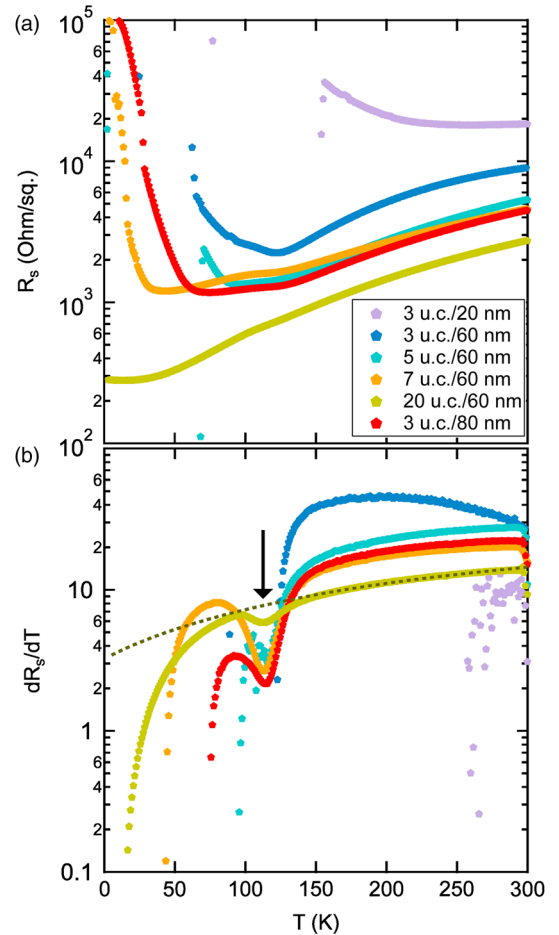


FIG. 2. (a) R_s as a function of the temperature for heterostructures with various SmTiO_3 (3, 5, 7, and 20 u.c.) and SrTiO_3 (20, 60, and 80 nm) thicknesses, respectively, as indicated in the legend. (b) Calculated dR_s/dT as a function of the temperature for the same structures. The arrow indicates the resistance anomaly at 110 K, which is observed for all samples. The dashed line is a fit to a power law, T^n , behavior of the 20 u.c. SmTiO_3 sample, which determined $n \sim 5/3$. The limited temperature range above T_{MIT} for the other samples precluded similar fits.

independent phenomena. Bulk SrTiO_3 has an antiferrodistortive transition at $\sim 110 \text{ K}$, and resistance anomalies have been observed to be associated with it [21–23], although their precise origin remains to be determined.

Figure 3 shows T_{MIT} as a function of the sheet carrier density (n_s), determined at room temperature from the Hall measurements (shown in Fig. 4). The room temperature n_s values systematically scale with the SmTiO_3 thickness [14]. They are 1.4×10^{14} , 2×10^{14} , 2.1×10^{14} , and $2.7 \times 10^{14} \text{ cm}^{-2}$ for the samples with 60 nm SrTiO_3 and 3, 5, 7, and 20 u.c. of SmTiO_3 , respectively; see Fig. 4(a). Here, T_{MIT} was defined as the temperature where $dR_s/dT \sim 0$. Figure 3 shows that T_{MIT} systematically and strongly depends on n_s . Even samples with different SrTiO_3

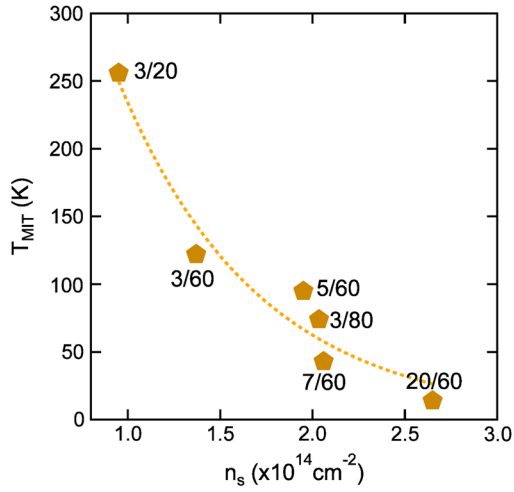


FIG. 3. T_{MIT} as a function of n_s for the samples shown in Fig. 2. The dotted line is a guide to the eye. The labels indicate the samples, with the first number referring to the SmTiO_3 thickness in number of unit cells and the second number to the SrTiO_3 thickness in nanometers. We note that for the sample with 20 u.c. of SmTiO_3 , which does not show an abrupt MIT, the temperature of the weak upturn in the resistance is shown instead.

thicknesses, which have slightly different mobilities and/or carrier densities than those with 60 nm SrTiO_3 , follow this general trend. Thus, the primary factor in determining T_{MIT} is the carrier density.

Figure 4 shows the results from Hall measurements. Figure 4(a) shows $(eR_H)^{-1}$, where R_H is the Hall coefficient and e the elementary charge, as a function of the temperature. In a simple metal with a single carrier type, $(eR_H)^{-1}$ corresponds to n_s . As mentioned above, n_s systematically scales with the SmTiO_3 thickness. As can be seen from the large error bars, below T_{MIT} , the samples became too resistive to obtain reliable measurements of R_H . The slight temperature dependence of $(eR_H)^{-1}$ above the transition is a consequence of the different temperature dependencies of the scattering rates that enter R_s and the Hall angle, $H\cot(\theta_H) = R_s/R_H$ (H is the magnetic field), respectively. For example, R_s is $\sim T^{5/3}$ for the 20 u.c. $\text{SmTiO}_3/60$ nm SrTiO_3 sample [see the dashed line in Fig. 2(b)], whereas $H\cot(\theta_H) \sim T^2$ [see Fig. 4(b)]. Since R_H is the ratio of the two, this causes a temperature dependence of R_H even when there is no actual change in the carrier density. The appearance of two different scattering rates, which cannot easily be explained within the Fermi-liquid theory, has become known as lifetime separation [24] and is sometimes thought to be a signature of proximity to a quantum critical point [25,26], but no definite explanation exists for it yet [27].

The Hall angle $H\cot(\theta_H)$ is shown in Fig. 4(b). We note that $H\cot(\theta_H) = \mu^{-1}$, where μ is the Hall mobility. The Hall angle follows a well-defined T^2 behavior to room temperature as described by

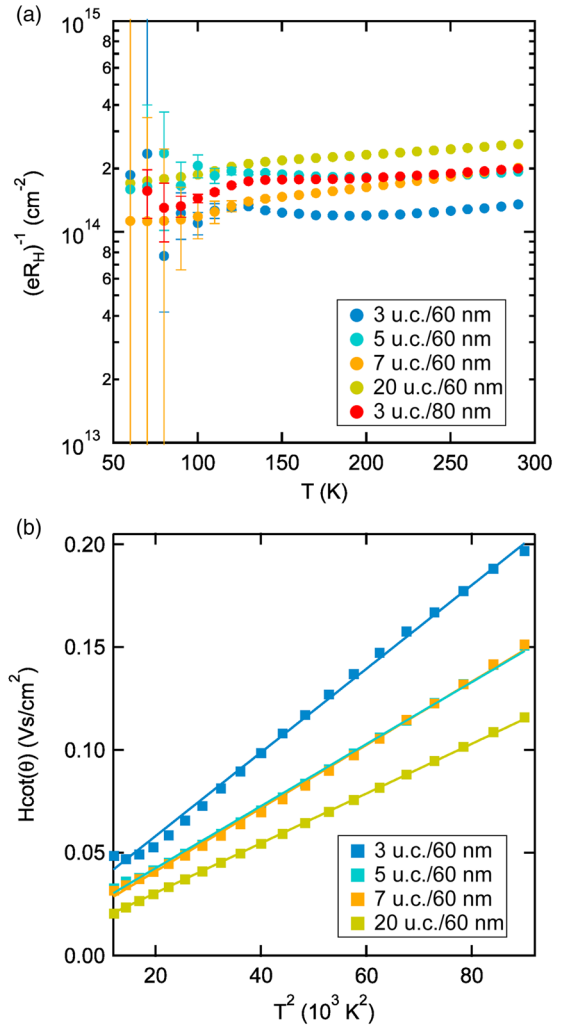


FIG. 4. (a) $(eR_H)^{-1}$ as a function of the temperature. Data below 50 K are not shown, as the resistances became too high for reliable Hall measurements for all samples except the one with 20 u.c. of SmTiO_3 (note the very large error bars at low temperatures). (b) $H\cot(\theta_H)$ as a function of T^2 . The lines are a fit to T^2 behavior that is used to obtain $H\alpha$, according to Eq. (1).

$$H\cot\theta_H = H(C + \alpha T^2), \quad (1)$$

where C is the residual and α is the Hall scattering amplitude. $H\alpha$ increases from 1.2×10^{-6} (Vs/cm^2)/ K^2 for the 20 u.c. $\text{SmTiO}_3/60$ nm SrTiO_3 sample to 2×10^{-6} (Vs/cm^2)/ K^2 for the 3 u.c. $\text{SmTiO}_3/60$ nm SrTiO_3 sample. The 3 u.c. $\text{SmTiO}_3/60$ nm SrTiO_3 sample displays slight deviations from T^2 behavior, in particular, in the proximity of the MIT.

We next discuss the results. First and foremost, we note that the MIT is very different from the MITs that are observed near the Mott-Ioffe-Regel limit (or quantum resistance) in a wide range of materials, such as two-dimensional electron gases in semiconductors [28] or oxide thin films [13,29]. In these cases, the MIT occurs near $R_s \sim 25$ $\text{k}\Omega/\square$, when the mean free path length is on the order of the lattice spacing

[30–32] (of course, the microscopic origins for the high resistance can be quite complex). The typical behavior near such MITs is insulating (or barely metallic) at all T ; i.e., there is no abrupt transition from metallic to insulating at a critical temperature. In the samples discussed here, only the 3 u.c. $\text{SmTiO}_3/20 \text{ nm SrTiO}_3$ sample with $R_s \sim 18 \text{ k}\Omega/\square$ falls likely into this category. This sample has a low mobility in addition to the low carrier density, which causes the high R_s . It does show, however, an abrupt MIT and was therefore included in Fig. 3. All other samples show an *abrupt* MIT even though R_s is *an order of magnitude below the Mott-Ioffe-Regel limit*. The insulator emerges from a state that is metallic—note the T^2 behavior of the Hall angle—and the insulator very quickly becomes highly resistive. Thus, the origin of the MIT observed here must lie in more unconventional physics.

The MIT is reminiscent of that in correlated materials, such as VO_2 [33] or the rare earth nickelates [34]. These materials also show an abrupt MIT as the temperature is lowered. However, the MIT in these materials is accompanied by a reduction of the lattice symmetry, and they exhibit a pronounced hysteresis indicative of a first-order transition. Here we do not observe a hysteresis, suggesting an electronic origin. The strongly insulating state is also striking. The Hall effect can still be measured well below T_{MIT} in charge-ordered systems such as the rare earth nickelates (though it may be nontrivial to interpret) [35].

Carrier densities in the samples here are low compared to strongly correlated materials. A significant portion of the carriers spread over the entire SrTiO_3 thickness [11,17,18]. This renders the carrier density at a fraction of the 1 electron/u.c. required of a Mott insulator. Even more crucially, T_{MIT} increases as we reduce the carrier density; this is opposite of what would be expected for physics driven by on-site Coulomb interactions, which should become more pronounced as the carrier density is *increased* towards half filling. Thus, it is unlikely that short-range Coulomb interactions are at the origin of the MIT in this system.

The key observation is that T_{MIT} increases with decreasing n_s . Moreover, the scattering amplitude α also increases with decreasing n_s . This indicates an increase in effective mass m^* , since $\alpha T^2 = (m^*/e)\Gamma(T^2)$, where Γ is a temperature-dependent scattering rate and e the elementary charge. A higher effective mass indicates stronger correlations in samples with lower n_s . Given the systematic dependence of these two independent quantities on n_s , long-range Coulomb interactions should be considered. To first order, their importance is determined by the ratio of the interaction energy (E_{e-e}) and the kinetic energy (Fermi energy E_F). This ratio is often expressed in terms of the Wigner-Seitz radius r_{WS} , which for a two-dimensional electron system is given as

$$r_{\text{WS}} = \frac{E_{e-e}}{E_F} = \frac{e^2 m^*}{\hbar^2 \epsilon} \frac{1}{\sqrt{\pi n_s}}, \quad (2)$$

where \hbar is the reduced Planck's constant and ϵ the dielectric constant. Using $m^* = 10$, which is not unrealistic for electrons in the $d_{yz,xz}$ -derived bands [36], $\epsilon = 300$ (undoped SrTiO_3 at room temperature [37]), and $n_s = 1 \times 10^{14} \text{ cm}^{-2}$, we obtain $r_{\text{WS}} \sim 5$, which is not high. Typically, electron systems are considered to be strongly correlated for $r_{\text{WS}} \sim 10$, with a value of 37 believed to be needed for the Wigner crystal in two dimensions [38]. However, several factors could increase r_{WS} substantially. First, multiple subbands are occupied in this system [17,39–41]. This will increase r_{WS} by factors corresponding to the subband degeneracy. Second, a substantial portion of the fixed charge at the interface remains unscreened if the mobile carrier density is less than $3 \times 10^{14} \text{ cm}^{-2}$. We believe the fixed charge at the polar interface is a key ingredient in the microscopic origins of this MIT, as no abrupt MITs with a change in temperature are observed either in bulk doped SrTiO_3 [42] or in other interfacial systems involving SrTiO_3 , such as $\text{LaAlO}_3/\text{SrTiO}_3$, at comparable (or even lower) carrier densities. One consequence of the polar fixed charge are very large, asymmetric electric fields, and thus Rashba-type spin-orbit coupling, which is believed to aid in the localization [12]. Finally, we note that the samples are certainly not free of disorder, which may promote unconventional metallic and insulating states even at small r_{WS} [7].

In conclusion, the observed mass enhancement, non-Fermi-liquid behavior, MITs at resistances much below the quantum resistance, and, most of all, the systematic scaling of T_{MIT} with the carrier density all point to an unconventional insulator in which long-range electron correlations play a key role. Future studies, though experimentally challenging, should be directed at determining the nature of the insulating state, in particular, with regards to magnetic order, or the absence thereof, and the spatial distribution of carriers. The results highlight the potential for new discoveries in MITs in material systems that are substantially different from the well-studied strongly correlated Mott insulators and dilute semiconductor systems. They also have implications for practical applications. The fact that T_{MIT} is highly sensitive to the carrier density makes this system of substantial interest for electric field gating of MITs. The relatively low (in comparison to strongly correlated materials) carrier densities promise an MIT that can be gated with conventional solid-state gate dielectrics, which has been a long-sought-after goal [43].

The authors thank Patrick Marshall, Santosh Raghavan, Leon Balents and Jim Allen for discussions. This work was supported in part by the Focus Center on Function Accelerated nanoMaterial Engineering (FAME), one of six centers of STARnet, a Semiconductor Research Corporation program sponsored by the Microelectronics Advanced Research Corporation and the Defense Advanced Research Projects Agency. The Materials

Research Science and Engineering Center Program of the National Science Foundation (Grant No. DMR 1121053) supported some of the facilities that were used in this study.

Note added in proof.—Recently, the authors became aware of Ref. [44], which theoretically studies orbital and spin order in two-dimensional electron gases at such interfaces.

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